	Application No.	Applicant(s)		
Notice of Allowability	09/902,728	MAHOROWALA,	MAHOROWALA, ARPAN P.	
	Examiner	Art Unit		
	Nicole M Barreca	1756		
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in or other appropriate communication is sufficiently. This application is sufficiently in the communication is sufficiently in the communication in the communication is sufficiently in the communication in the communica	this application. If not inclinication will be mailed in di	uded ue course THIS	
1. \square This communication is responsive to $7/1/04$.				
2. The allowed claim(s) is/are 1-17,20 and 21.				
3. The drawings filed on are accepted by the Examine	r.			
 4. ☐ Acknowledgment is made of a claim for foreign priority una) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents have 2. ☐ Certified copies of the priority documents have 3. ☐ Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). 	be been received. be been received in Application	No	cation from the	
* Certified copies not received:				
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file a IENT of this application.	a reply complying with the i	requirements	
5. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give	itted. Note the attached EXAMes reason(s) why the oath or o	MINER'S AMENDMENT or declaration is deficient.	NOTICE OF	
6. CORRECTED DRAWINGS (as "replacement sheets") mus	t be submitted.			
(a) ☐ including changes required by the Notice of Draftspers		(PTO-948) attached		
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date		,		
(b) ☐ including changes required by the attached Examiner's Paper No./Mail Date	s Amendment / Comment or in	n the Office action of		
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the	.84(c)) should be written on the ne header according to 37 CFR	drawings in the front (not t	he back) of	
 DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT I 	BIOLOGICAL MATER FOR THE DEPOSIT OF BIOL	RIAL must be submitted OGICAL MATERIAL.	. Note the	
Attachment(s)				
1. Notice of References Cited (PTO-892)	5. Notice of Info	rmal Patent Application (P	TO-152)	
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. 🔲 Interview Sun	nmary (PTO-413),	,	
 Information Disclosure Statements (PTO-1449 or PTO/SB/0- Paper No./Mail Date 		ail Date mendment/Comment		
4. Examiner's Comment Regarding Requirement for Deposit	8. ⊠ Examiner's S	tatement of Reasons for Al	llowance	
of Biological Material	9. 🗌 Other			

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DETAILED ACTION

Response to Amendment

1. The declaration filed on 7/1/04 under 37 CFR 1.131 is sufficient to overcome the Ngo reference. The applicant declares that the pictures on Figures 4A and 4B were taken on July 7, 2000 and therefore that the invention was reduced to practice on that date.

Drawings

- 2. Authorization for this examiner's amendment was given in a telephone interview with John Evans on 8/11/04.
- 3. The following changes to the drawings have been approved by the examiner and agreed upon by applicant: Each bottom figure on page 1, 2 and 4 of the drawings will be labeled "FIG. 1B", "FIG. 2B" and "FIG. 4B", respectively. In order to avoid abandonment of the application, applicant must make these above agreed upon drawing changes.

Allowable Subject Matter

- 4. Claims 1-17 and 20-21 are allowed.
- 5. The following is an examiner's statement of reasons for allowance: the prior art fails to teach or suggest a method for forming a high aspect ratio, post-etch lithographic feature against collapse comprising transferring the image to the organic underlayer from the photoresist which comprises materials that form stable, etch-resistant, non-volatile oxide in order to form a high aspect ratio resist image and then treating this bilayer resist image with a chemically reducing plasma.

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Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Nicole M Barreca whose telephone number is 571-272-1379. The examiner can normally be reached on Monday-Thursday (9AM-7PM).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark Huff can be reached on 571-272-1385. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Nmb 8/11/04

NB

JOHN'A. MCPHERSON PRIMÄRY EXAMINER